

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

PRELIMINARY AMENDMENT ACCOMPANYING APPLICATION

APPLICANT: Hideo Yamanaka, et al. ATTY. DOCKET NO. 09792909-5337

SERIAL NO.

DATE FILED:

INVENTION: "METHOD AND APPARATUS FOR FORMING A THIN
SEMICONDUCTOR FILM, METHOD AND APPARATUS FOR
PRODUCING A SEMICONDUCTOR DEVICE, AND ELECTRO-
OPTICAL APPARATUS"

Assistant Commissioner of Patents
Washington, D.C. 20231

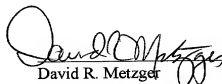
S I R:

Between the title and the heading "Background of the Invention" on page 1, insert the
following:

--RELATED APPLICATION DATA

The present application claims priority to Japanese Application(s) No(s). P2001-036441
filed February 14, 2001, which application(s) is/are incorporated herein by reference to the extent
permitted by law.--

Respectfully submitted,



(Reg. No. 32,919)

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